

Dielectric Barrier Discharge Source for generating beam of nanoparticles (Ramot)

code: 11-2013-631

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A method of fabricating a film. The method comprises directing onto a substrate a pulsed supersonic beam of a molecular precursor characterized by kinetic energy of at least 1 eV per molecule, such that non-volatile species of molecules of the precursor are deposited on the substrate.

Additional information can be provided upon request.

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